

B¹ Sub C¹ } 1. (Amended) A wiring comprising a Cu (copper) layer surrounded along at least one side by a first coating film made of titanium and surrounded along at least three sides by a second coating film made of titanium oxide.

B² Sub C² } 11. (Amended) A TFT (thin film transistor) substrate having a wiring as claimed in claim 1.

B³ } 20. (Amended) An LCD (liquid crystal display) comprising a pair of opposing substrates and a liquid crystal disposed between the opposing substrates, wherein at least one of the pair of opposing substrates is a TFT substrate as claimed in claim 11.

[Please add new dependent claim 21 as follows:]

B⁴ } 21. (New) The wiring according to claim 1, wherein the Cu (copper) layer is surrounded along at least four sides by the first coating film.